

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:	)	<b>CONFIRMATION NO.: 1005</b>
	)	
<b>Yasuo KOBAYASHI, et al.</b>	)	
	)	
U.S. Serial No.: 10/568,461	)	Group Art Unit: 2812
	)	
Filed: February 15, 2006	)	Examiner: Reema Patel
For: SEMICONDUCTOR DEVICE, MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE, AND GAS FOR PLASMA CVD PROCESS		

**RESPONSE TO OFFICE ACTION DATED APRIL 10, 2009**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

A reply to the Office Action of April 10, 2009 was due by July 10, 2009. Submitted herewith, together with the requisite fee, is a Petition for extending the time of reply up to and including October 10, 2009. Please accept these papers as timely filed.

Please further consider this application as follows.